

Mean: 26.4
Median: 28
Std. Dev: 10.4

The test is open book/open notes. Show all work. Be sure to state all assumptions made and check them when possible. The number of points per problem are indicated in parentheses (50 total).

1. The electron concentration in a region of silicon depends linearly on depth with concentration of $5 \times 10^{15} \text{ cm}^{-3}$ at surface ($x = 0$) and 10^{15} cm^{-3} at depth of $x = 500 \text{ nm}$. If the vertical electron current density in this region is constant at $J_n = 100 \text{ A/cm}^2$, calculate the electric field near $x = 500 \text{ nm}$. You may assume that the mobility is constant at $1250 \text{ cm}^2/\text{Vs}$. (12)

$$J_n = q(\mu_n n \mathcal{E} + D_n \frac{dn}{dx})$$

$$\mu_n = 1250 \frac{\text{cm}^2}{\text{V.s}} \quad D_n = \frac{kT}{q} \mu_n$$

$$n(500 \text{ nm}) = 10^{15} \text{ cm}^{-3}$$

$$\left. \frac{dn}{dx} \right|_{500 \text{ nm}} = \frac{10^{15} - 5 \times 10^{15}}{5 \times 10^{-5} \text{ cm}} \text{ cm}^{-3}$$

$$= 8 \times 10^{19} \text{ cm}^{-4}$$

$$J_n = q \mu_n \left(n \mathcal{E} + \frac{kT}{q} \frac{dn}{dx} \right)$$

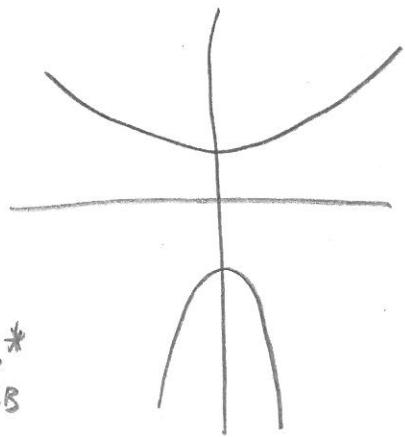
$$\mathcal{E} = \frac{1}{n} \left[\frac{J_n}{q \mu_n} - \frac{kT}{q} \frac{dn}{dx} \right] = \frac{1}{10^{15} \text{ cm}^{-3}} \left[\frac{100 \text{ A/cm}^2}{(1.6 \times 10^{-19} \text{ e})(1250 \frac{\text{cm}^2}{\text{V.s}})} \right.$$

$$\left. - (0.026 \text{ V}) (8 \times 10^{19} \text{ cm}^{-4}) \right]$$

$$= 10^{-15} \text{ cm}^3 \left[\frac{100 \text{ V/cm}^4}{2 \times 10^{16}} - 2.08 \times 10^{-18} \frac{\text{V}}{\text{cm}^4} \right]$$

$$= 2.58 \times 10^3 \frac{\text{V}}{\text{cm}} = 2580 \frac{\text{V}}{\text{cm}}$$

2. (a) Sketch the band diagram (E vs. k along main symmetry directions) for a semiconductor which has $\mu_p > \mu_n$ and $N_v < N_c$. The qualitative relations should be clear from your sketch. Assume scattering lifetimes are equal for holes and electrons. Briefly note reasoning. (10)



$$i) \mu_p = \frac{q\tau_p}{m_h^*}, \mu_n = \frac{q\tau_n}{m_e^*} \quad \mu_p > \mu_n \Rightarrow \frac{1}{m_h^*} > \frac{1}{m_e^*}$$

$$\tau_p = \tau_n \quad \Rightarrow \left(\frac{dE}{dk^2} \right)^{VB} > \left(\frac{d^2E}{dk^2} \right)^{CB}$$

$$ii) N_v = 2N_{\max} \left(\frac{2\pi m_h^* kT}{h^2} \right)^{3/2}$$

$$N_v < N_c \Rightarrow m_h^* < m_e^* \text{ and/or } N_{\max}^{VB} < N_{\min}^{CB}$$

- (b) Calculate the intrinsic carrier concentration at 300 K in a semiconductor which has a single valence band maxima given by $E = E_v - (\hbar^2 k^2 / 2m_0)$ and eight conduction band minima in the $\langle 111 \rangle$ directions with $E = E_c + 2\hbar^2(k - k_0)^2/m_0$ where $k_0 = (\pm a, \pm a, \pm a)$, $E_c - E_v = 1 \text{ eV}$ and m_0 is the free electron mass. (10)

$$n_i = \sqrt{N_c N_v} \exp(-E_g/2kT)$$

$$E_g = E_c - E_v = 1 \text{ eV}$$

$$N_c = 2N_{\min} \left(\frac{2\pi m_e^* kT}{h^2} \right)^{3/2}$$

↑
8

$$m_e^* = \frac{\hbar^2}{\left(\frac{d^2E}{dk^2} \right)_{CB}} = \frac{\hbar^2}{4\hbar^2/m_0} = \frac{m_0}{4}$$

$$N_v = 2 \left(\frac{2\pi m_h^* kT}{h^2} \right)^{3/2} \quad m_h^* = m_0$$

$$n_i = 2 \left(\frac{2\pi m_0 kT}{h^2} \right)^{3/2} \cdot \left[8 \left(\frac{1}{4} \right)^{3/2} (1)^{3/2} \right]^{1/2} \exp \left(- \frac{1 \text{ eV}}{0.052 \text{ eV}} \right)$$

$$= 2 \left(\frac{2\pi (9.11 \times 10^{-31} \text{ kg})(0.026 \text{ eV})}{(6.63 \times 10^{-34} \text{ J s})(4.14 \times 10^{-15} \text{ eV})} \right)^{3/2} \cdot 4.45 \times 10^{-9} = 1.12 \times 10^{17} \text{ m}^{-3}$$

$$= 1.12 \times 10^{11} \text{ cm}^{-3}$$

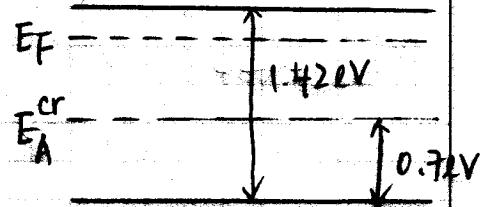
Exam 1.

3(a) $N_D = 10^{16} \text{ cm}^{-3}$ $N_A = 2 \times 10^{15} \text{ cm}^{-3}$ → assume all shallow dopants → fully ionized.
 assume that this is an n-type material

Steps: $E_F > E_{F_i}$ & $E_F > E_A^{cr}$.

- Proof of assumptions Need to find N_A^{cr} , so that $n = 10^9 \text{ cm}^{-3}$

- Neutrality @ $n = 10^9 \text{ cm}^{-3}$ $\Rightarrow N_c \exp\left(-\frac{E_c - E_F}{kT}\right)$



$$E_F - E_c = -kT \ln \frac{N_c}{n} = -25 \text{ meV} \ln \left(\frac{4.3 \times 10^{17} \text{ cm}^{-3}}{10^9 \text{ cm}^{-3}} \right) \quad (4)$$

$$= -0.497 \text{ eV} \quad (0.514 \text{ eV})$$

$$E_F - E_A^{cr} = Eg - (E_c - E_F) - (E_A^{cr} - E_v) \quad \text{if } 25.9 \text{ meV was used}$$

$$= (1.42 - 0.497 - 0.7) \text{ eV} = 0.223 \text{ eV} \quad (> 3kT) \quad (4)$$

Cr is fully ionized because E_A^{cr} is below E_F .

Material neutrality gives: $n = N_D^+ - N_A^- - N_A^{cr}$

Main issue: - used pre-doping level $N_A^{cr} = (10^{16} - 2 \times 10^{15} - 10^9) \text{ cm}^{-3}$
 to calculate E_F

- assume ionization without proving $\approx 8.00 \times 10^{15} \text{ cm}^{-3}$ (3 s.f.) (2)
 - flipped the e- & hole relationship.

(b) $n = 10^9 \text{ cm}^{-3}$ $\boxed{n \text{ is the majority carrier, not p.}}$

$$P = \frac{n^2}{n} = \frac{(2.4 \times 10^6)^2}{10^9} \text{ cm}^{-3} = 5760 \text{ cm}^{-3}.$$

(3) ← 1 for
correct
 μ .

$$P = \frac{1}{g_m \mu_p + g_m \mu_n} = \frac{1}{(1.6 \times 10^{-19} C)(6 \times 10^3 \frac{\text{cm}}{\text{Vs}})(10^9 \text{ cm}^{-3})}$$

$$\downarrow \text{negligible} \quad = \underline{1.04 \text{ M}\Omega \cdot \text{cm}} \quad \uparrow \quad (1)$$

$$R_\square = \frac{1}{\int_{200 \mu m}^{\infty} g_m \mu_n dx} = \frac{P}{200 \times 10^{-4} \text{ cm}} \quad (3)$$

$$= \underline{52.1 \text{ M}\Omega} \quad (1)$$

$$\begin{aligned} \text{Total doping} &= (10^{16} + 2 \times 10^{15} + \\ &\quad 8 \times 10^{15}) \text{ cm}^{-3} \\ &= 2 \times 10^{16} \text{ cm}^{-3} \end{aligned}$$

Main issue: - used pre-doping p to calculate P.
 - forgot that μ_s are related to total doping